



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 10/678,513  
Filing Date ..... October 3, 2003  
Inventor ..... Werner Juengling  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2823  
Examiner ..... Brook Kebede  
Attorney's Docket No. .... MI22-2391  
Customer No. .... 021567  
Title: Semiconductor Processing Methods Of Forming A Contact Opening To A Conductive Line and Methods of Forming Substrate Active Area Source/Drain Regions

RESPONSE TO NOVEMBER 10, 2005 FINAL OFFICE ACTION  
ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION (RCE)

To: Mail Stop: RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

From: D. Brent Kenady  
Tel. 509-624-4276; Fax 509-838-3424  
Wells St. John P.S.  
601 W. First Avenue, Suite 1300  
Spokane, WA 99201-3817

Responsive to the Final Office Action dated November 10, 2005, Applicant amends and remarks as follows:

AMENDMENTS

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.

EV850818545